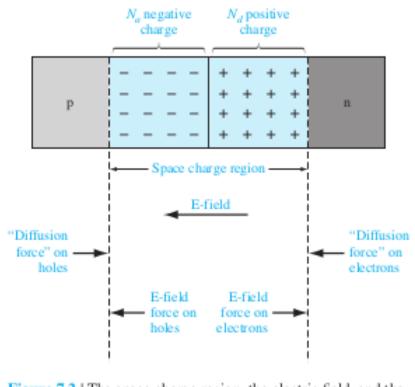
### The pn junction under forward and reverse bias ${\it Thorbjørn~Erik~Køppen~Christensen}$ ${\it June~20,~2018}$

# Part I The pn junction

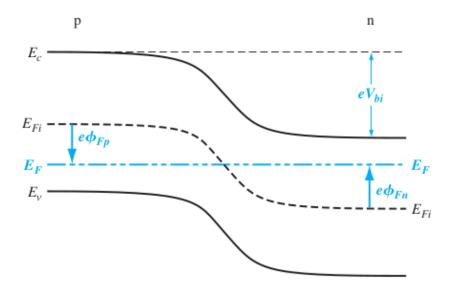
#### 1 Basic structure of the pn junction

A space charge region appears between the n and p junctions:



Note the space charge region and how the electrons from the n-type move to the holes in the p-type

#### 2 Zero applied Bias



$$V_{bi} = |\phi_{Fn}| + |\phi_{Fp}|$$

 $V_{bi}$  is the build in potential barrier, the  $\phi$  values are the differences in from the Fermi level to the intrinsic Fermi level, in the n region  $(N_d \approx n_0)$ 

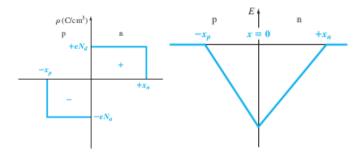
$$\begin{split} n_0 &= N_c \exp\left[-\frac{E_c - E_F}{kT}\right] = n_i \exp\left[\frac{E_F - E_{Fi}}{kT}\right] \\ e\phi_{Fn} &= E_{Fi} - E_F \\ n_0 &= N_c \exp\left[-\frac{e\phi_{Fn}}{kT}\right] \end{split}$$

For the p type

$$\begin{split} p_0 = N_a = n_i \exp\left[\frac{E_{Fi} - E_F}{kT}\right] = n_i \exp\left[\frac{e\phi_{Fp}}{kT}\right] \\ \phi_{Fn} = -\frac{kT}{e} \ln\left(\frac{N_d}{n_i}\right) \qquad \phi_{Fp} = +\frac{kT}{e} \ln\left(\frac{N_a}{n_i}\right) \end{split}$$

Thus:

$$V_{bi} = V_t \ln \left( \frac{N_a N_d}{n_i^2} \right)$$



Here it's assumed that the space charge region is strictly within  $-x_p-x_n$ .

$$\frac{d^2\phi(x)}{dx^2} = \frac{-\rho(x)}{\epsilon_s} = -\frac{dE(x)}{dx}$$

$$\rho(x) = \begin{cases} -eN_a & \forall x \in [-x_p; 0] \\ eN_d & \forall x \in [0; x_n] \end{cases}$$

$$E = \int \frac{\rho(x)}{\epsilon_s} dx = -\int \frac{eN_a}{\epsilon_s} dx = -\frac{eN_a}{\epsilon_s} x + C_1$$

$$E = -\int \frac{eN_d}{\epsilon_s} dx = \frac{eN_d}{\epsilon_s} x + C_1$$

 $C_1$  and  $C_2$  is from integration, now let E=0 at  $x=-x_p$  and  $x=x_n$ :

$$\begin{split} E &= \begin{cases} -\frac{eN_a}{\epsilon_s}(x+x_p) & \forall x \in [-x_p;0] \\ \frac{eN_d}{\epsilon_s}(x-x_n) & \forall x \in [0;x_n] \end{cases} \\ N_a x_p &= N_d x_n \\ \phi(x) &= -\int E(x) \, dx \\ &= \int \frac{eN_a}{\epsilon_s}(x+x_p) \, dx \\ &= \frac{eN_a}{\epsilon_s}(\frac{x^2}{2} + x \cdot x_p) + C_1' \, dx \\ C_1' &= \frac{eN_a}{2\epsilon_s} x_p^2 \quad \text{because of the zero location} \\ \phi(x) &= \frac{eN_a}{2\epsilon_s}(x+x_p)^2 \quad \forall x \in [-x_p;0] \end{split}$$

now for the n region:

$$\phi(x) = \int \frac{eN_d}{\epsilon_s} (x - x_n) dx$$

$$= \frac{eN_d}{\epsilon_s} (x \cdot x_n - \frac{x^2}{2}) + C_2' dx$$

$$C_2' = C_1'$$

$$\phi(x) = \frac{eN_d}{\epsilon_s} \left( x \cdot x_n - \frac{x^2}{2} \right)^2 + \frac{eN_a}{2\epsilon_s} x_p^2 \quad \forall x \in [0; x_n]$$

$$V_{bi} = \frac{e}{2\epsilon_s} \left( N_d x_n^2 + N_a x_p^2 \right) = |\phi(x = x_n)|$$

Space charge width:

$$x_p = \frac{N_d}{N_a} x_n$$

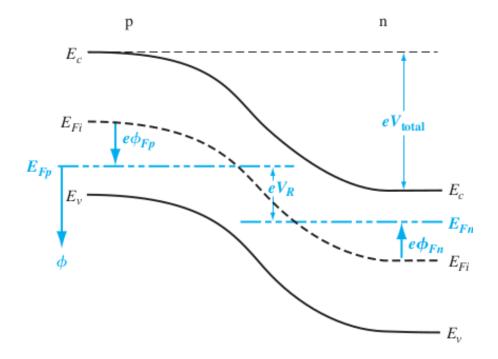
$$x_n = \left\{ \frac{2\epsilon_s V_{bi}}{e} \left[ \frac{N_a}{N_d} \right] \left[ \frac{1}{N_a + N_d} \right] \right\}^{\frac{1}{2}}$$

$$x_p = \left\{ \frac{2\epsilon_s V_{bi}}{e} \left[ \frac{N_d}{N_n} \right] \left[ \frac{1}{N_a + N_d} \right] \right\}^{\frac{1}{2}}$$

$$W = x_n + x_p = \left\{ \frac{2\epsilon_s V_{bi}}{e} \left[ \frac{N_a + N_d}{N_a N_d} \right] \right\}^{\frac{1}{2}}$$

#### 3 Reverse applied bias

Reverse bias: Positive on the n side



$$\begin{split} V_{\text{total}} &= |\phi_{Fn}| + |\phi_{Fp}| + V_R \\ &= V_{bi} + V_R \end{split}$$

New width:

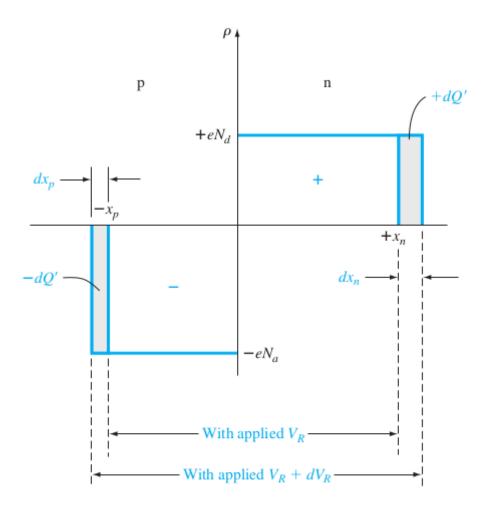
$$W = x_n + x_p = \left\{ \frac{2\epsilon_s(V_{bi} + V_R)}{e} \left[ \frac{N_a + N_d}{N_a N_d} \right] \right\}^{\frac{1}{2}}$$

$$E_{\text{max}} = -\frac{eN_d x_n}{\epsilon_s} = -\frac{eN_a x_p}{\epsilon_s}$$

$$= -\sqrt{\frac{2e(V_{bi} + V_R)}{\epsilon_s} \left( \frac{N_a N_d}{N_a + N_d} \right)}$$

$$= -\frac{2(V_{bi} + V_R)}{W}$$

Junction capacitance:



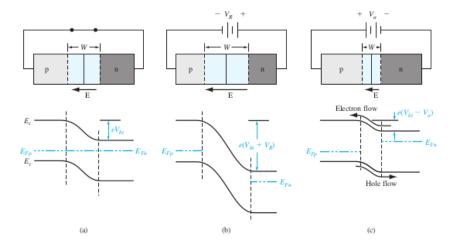
$$\begin{split} dQ' &= eN_d dx_n = eN_a dx_p \\ C' &= \frac{dQ'}{dV_R} = eN_d \frac{dx_n}{dV_R} \\ &= \sqrt{\frac{e\epsilon_s N_a N_d}{2(V_{bi} + V_R)(N_a + N_d)}} = \frac{\epsilon_s}{W} \end{split}$$

One sided junction  $(N_a \gg N_d,$  known as  $p^+n$  junction, opposite the other way)

$$W \approx \sqrt{\frac{2\epsilon_s(V_{bi} + V_R)}{eN_d}}$$
$$x_p \ll x_n$$
$$W \approx x_n$$
$$C' \approx \sqrt{\frac{e\epsilon_s N_d}{2(V_{bi} + V_R)}}$$

## Part II The pn junction diode

#### 4 pn junction current



- The abrupt depletion layer approximation applies. The space charge regions have abrupt boundaries, and the semiconductor is neutral outside of the depletion region.
- $\bullet$  The Maxwell–Boltzmann approximation applies to carrier statistics.
- The concepts of low injection and complete ionization apply.
- The total current is a constant throughout the entire pn structure.
  - The individual electron and hole currents are continuous functions through the pn structure.
  - The individual electron and hole currents are constant throughout the depletion region.

$$\begin{aligned} V_{bi} &= V_t \ln \left( \frac{N_a N_d}{n_i^2} \right) \\ \frac{n_i^2}{N_a N_d} &= \exp \left( -\frac{e V_{bi}}{k T} \right) \\ n_{n0} &\approx N_d \\ n_{p0} &\approx \frac{n_i^2}{N_a} \\ n_{p0} &= n_{n0} \exp \left( -\frac{e V_{bi}}{k T} \right) \end{aligned}$$

 $n_n$  is the majority carrier electrons,  $n_p$  is the concentration of minority carrier electrons.

$$n_p = n_{p0} \exp\left(\frac{eV_a}{kT}\right)$$
$$p_n = p_{n0} \exp\left(\frac{eV_a}{kT}\right)$$

Minority carrier distribution

$$\frac{\partial(\delta p_n)}{\partial t} = D_p \frac{\partial^2(\delta p_n)}{\partial x^2} - \mu_p E \frac{\partial \delta p_n}{\partial x} + g' - \frac{\partial p_n}{\tau_{p0}}$$

$$\frac{d^2 \delta p_n}{dx^2} - \frac{\delta p_n}{L_p^2} = 0 \qquad (x > x_n), L_p^2 = D_p \tau_{p0}$$

$$\frac{d^2 \delta n_p}{dx^2} - \frac{\delta n_p}{L_n^2} = 0 \qquad (x > x_n), L_n^2 = D_n \tau_{n0}$$

$$p_n(x_n) = p_{n0} \exp\left(\frac{eV_a}{kT}\right) \xrightarrow[x \to \infty]{} p_{n0}$$

$$n_p(-x_p) = n_{p0} \exp\left(\frac{eV_a}{kT}\right) \xrightarrow[x \to \infty]{} n_{p0}$$

$$\delta p_n(x) = p_n(x) - p_{n0} = Ae^{\frac{x}{L_p}} + Be^{-\frac{x}{L_p}}$$

$$= p_{n0} \left[\exp\left(\frac{eV_a}{kT}\right) - 1\right] \exp\left(\frac{x_n - x}{L_p}\right)$$

$$\delta n_p(x) = n_p(x) - n_{p0} = Ce^{\frac{x}{L_n}} + De^{-\frac{x}{L_n}}$$

$$= n_{p0} \left[\exp\left(\frac{eV_a}{kT}\right) - 1\right] \exp\left(\frac{x_p - x}{L_n}\right)$$

$$p = p_0 + \delta p = n_i \exp\left(\frac{E_{F_i} - E_{F_p}}{kT}\right)$$

$$n = n_0 + \delta n = n_i \exp\left(\frac{E_{F_n} - E_{F_i}}{kT}\right)$$

At the space charge edge:

$$n_0 p_n(x_n) = n_0 p_{n0} \exp\left(\frac{V_a}{V_t}\right) = n_i^2 \exp\left(\frac{V_a}{V_t}\right)$$
$$np = n_i^2 \exp\left(\frac{E_{Fn} - E_{Fp}}{kT}\right)$$

Ideal pn junction current

$$J_p(x_n) = -eD_p \frac{dp_n(x)}{dx} \Big|_{x=x_n}$$

$$J_p(x_n) = -eD_p \frac{d\delta p_n(x)}{dx} \Big|_{x=x_n}$$

$$= \frac{eD_p p_{n0}}{L_p} \left[ \exp\left(\frac{eV_a}{kT}\right) - 1 \right]$$

$$J_n(-x_p) = \frac{eD_n n_{p0}}{L_n} \left[ \exp\left(\frac{eV_a}{kT}\right) - 1 \right]$$

$$J = \underbrace{\left[\frac{eD_p p_{n0}}{L_p} + \frac{eD_n n_{p0}}{L_n}\right]}_{I} \left[ \exp\left(\frac{eV_a}{kT}\right) - 1 \right]$$

### 5 Generation-recombination currents and high-injection levels

$$R = \frac{C_n C_p N_t (np - n_i^2)}{C_n (n + n') + C_p (p + p')}$$

Reverse bias:

$$R = \frac{-C_n C_p N_t n_i^2}{C_n n' + C_p p'}$$

$$= \frac{-n_i}{\frac{1}{N_t C_p} + \frac{1}{N_t C_n}}$$

$$= \frac{-n_i}{2\tau_0} \quad \tau_0 = \frac{\tau_{p0} + \tau_{n0}}{2}$$

$$J_{gen} = \int_0^w eG \, dx = \frac{en_i W}{2\tau_0}$$

$$J_R = J_s + J_{gen}$$

Forward bias:

$$R = \frac{np - n_i^2}{\tau_{p0}(n + n') + \tau_{n0}(p + p')}$$

$$n = n_i \exp\left[\frac{E_{Fn} - E_{Fi}}{kT}\right]$$

$$p = n_i \exp\left[\frac{E_{Fi} - E_{Fp}}{kT}\right]$$

figure 8.13

$$eV_a = (E_{Fn} - E_{Fi}) + (E_{Fi} - E_{Fp})$$

At the space charge region center:

$$\frac{eV_a}{2} = E_{Fn} - E_{Fi} = E_{Fi} - E_{Fp}$$

$$n = n_i \exp\left[\frac{eV_a}{2kT}\right]$$

$$p = n_i \exp\left[\frac{eV_a}{2kT}\right]$$

$$R_{max} = \frac{n_i}{2\tau_0} \frac{\exp\left(\frac{eV_a}{kT}\right) - 1}{\exp\left(\frac{eV_a}{kT}\right) + 1}$$

ignoring the ones  $(V_a \gg kT/e)$ 

$$= \frac{n_i}{2\tau_0} \exp\left(\frac{eV_a}{2kT}\right)$$

$$J_{rec} = \int_0^{\infty} eR \, dx = ex' \frac{n_i}{2\tau_0} \exp\left(\frac{eV_a}{2kT}\right)$$

$$= \underbrace{\frac{eWn_i}{2\tau_0}}_{J_{ro}} \exp\left(\frac{eV_a}{2kT}\right)$$

$$J = J_{rec} + J_D$$

$$J_D = J_s \exp\left(\frac{eV_a}{kT}\right)$$

$$\ln J_{rec} = \ln J_{r0} + \frac{V_a}{2V_t}$$

$$\ln J_D = \ln J_s + \frac{V_a}{2V_t}$$

$$I = I_s \left[\exp\left(\frac{V_a}{nV_t}\right) - 1\right]$$

This n is not n but the ideality factor, now for high level injection:

$$np = n_i^2 \exp\left(\frac{V_a}{V_t}\right)$$
$$(n_0 + \delta n)(p_0 + \delta p) = n_i^2 \exp\left(\frac{V_a}{V_t}\right)$$
$$\delta n \delta p \approx n_i^2 \exp\left(\frac{V_a}{V_t}\right)$$
$$\delta n = \delta p \approx n_i^2 \exp\left(\frac{V_a}{2V_t}\right)$$
$$I \propto \exp\left(\frac{V_a}{2V_t}\right)$$